

**IN THE CLAIMS**

Please amend the claims as follows:

Claim 1 (amended): A multilayer printed wiring board comprising:

a substrate [provided with] having at least one through-hole structure, [the substrate having] the at least one through-hole structure comprising a plated film and being filled with a filler;

at least one interlaminar resin insulating layer formed [thereon] on the substrate; and  
at least one conductor circuit formed on the at least one interlaminar resin insulating layer[, the at least one through-hole being filled with filler],

wherein [an internal] a surface of the plated film of the at least one through-hole structure is roughened, and the filler comprises metal particles and one of thermosetting and thermoplastic [resin] resins.

Claim 2: The multilayer printed wiring board according to claim 1, wherein the substrate is a multilayer core substrate formed by laminating at least one conductor layer and at least one prepreg in alternating order.

Claim 3 (amended): The multilayer printed wiring board according to claim 1, wherein at least one through-hole structure formed [on] in the substrate has a pitch interval of equal to or less than 700  $\mu\text{m}$ .

Claim 4 (amended): The multilayer printed wiring board according to claim 1, [comprising build-up wiring layers including at least one via-hole provided in the at least one interlaminar resin insulating layer] wherein the at least one interlaminar resin insulating layer comprises a plurality of interlaminar resin insulating layers, the plurality of interlaminar resin insulating layers and at least one via-hole provided in the interlaminar resin insulating layers to form build-up wiring layers, and the build-up wiring layers are formed on both surfaces of

the substrate[, ] and have the same number of layers [with each other] on both surfaces of the substrate.

Claim 5 (amended): A multilayer printed wiring board comprising:  
a substrate [provided with] having at least one through-hole structure, [the substrate having] the at least one through-hole structure being filled with a filler;  
at least one interlaminar resin insulating layer formed [thereon] on the substrate; and  
at least one conductor circuit formed on the at least one interlaminar resin insulating layer[, the at least one through-hole being filled with filler],  
wherein an internal surface of the at least one through-hole structure is roughened,  
and the filler comprises a particulate substance including metal particles having a particle size of from 0.1 to 30  $\mu\text{m}$ , a resin, and an ultrafine inorganic powder having a particle size from [1 to 1000] 2 to 100 nm.

Claim 6 (amended): The multilayer printed wiring board according to claim 5,  
wherein the filler is a nonconducting composition [containing metal particles].

Claim 7 (amended): The multilayer printed wiring board according to claim 5,  
wherein the particulate substance further comprises at least one of [metal particles,] inorganic particles and resin particles.

Claim 8: The multilayer printed wiring board according to claim 5, wherein the resin comprises at least one of bisphenol epoxy resin and novolac epoxy resin.

Claim 9: The multilayer printed wiring board according to claim 5, wherein the substrate is a multilayer core substrate formed by laminating at least one conductor layer and at least one prepeg in alternating order.

Claim 10 (amended): The multilayer printed wiring board according to claim 5,  
wherein the at least one through-hole structure formed [on] in the substrate has a pitch interval of equal to or less than 700  $\mu\text{m}$ .

Claim 11 (amended): The multilayer printed wiring board according to claim 5, [comprising build-up wiring layers including at least one via-hole provided in the at least one interlaminar resin insulating layer] wherein the at least one interlaminar resin insulating layer comprises a plurality of interlaminar resin insulating layers, the plurality of interlaminar resin insulating layers and at least one via-hole provided in the interlaminar resin insulating layers to form build-up wiring layers, and the build-up wiring layers are formed on both surfaces of the substrate[, ] and have the same number of layers [with each other] on both surfaces of the substrate.

Claim 12 (amended): A multilayer printed wiring board comprising:

a substrate [provided with] having at least one through-hole structure, [the substrate having] the at least one through-hole structure comprising a plated film and being filled with a filler;

at least one interlaminar resin insulating layer formed [thereon] on the substrate; and  
at least one conductor circuit formed on the at least one interlaminar resin insulating layer[, the at least one through-hole being filled with filler],

wherein [an internal] a surface of the plated film of the at least one through-hole structure is roughened, [and] the filler comprises metal particles and one of thermosetting and thermoplastic [resin] resins, and an exposed portion of the filler in the at least one through-hole is covered with a [portion of the at least one conductor circuit] through-hole-covering conductor layer.

Claim 13 (amended): The multilayer printed wiring board according to claim 12, wherein [a roughened layer is formed on] a surface of the [at least one conductor circuit] through-hole-covering conductor layer covering at least the one through-hole structure is roughened.

Claim 14: The multilayer printed wiring board according to claim 12, wherein the substrate is a multilayer core substrate formed by laminating at least one conductor layer and at least one prepreg in alternating order.

Claim 15 (amended): The multilayer printed wiring board according to claim 12, wherein the at least one through-hole structure formed [on] in the substrate has a pitch interval of equal to or less than 700  $\mu\text{m}$ .

Claim 16 (amended): The multilayer printed wiring board according to claim 12, [comprising build-up wiring layers including the at least one via-hole provided in the at least one interlaminar resin insulating layer] wherein the at least one interlaminar resin insulating layer comprises a plurality of interlaminar resin insulating layers, the plurality of interlaminar resin insulating layers and at least one via-hole provided in the interlaminar resin insulating layers to form build-up wiring layers, and the build-up wiring layers are formed on both surfaces of the substrate[,] and have the same number of layers [with each other] on both surfaces of the substrate.

Claim 17 (amended): A multilayer printed wiring board comprising:  
a substrate [provided with] having at least one through-hole structure, [the substrate having] the at least one through-hole structure being filled with a filler;

at least one interlaminar resin insulating layer formed [thereon] on the substrate; and  
at least one conductor circuit formed on the at least one interlaminar resin insulating layer[, the at least one through-hole being filled with filler],

wherein an internal surface of the at least one through-hole structure is roughened,  
[and] the filler comprises a particulate substance having a particle size of from 0.1 to 30  $\mu\text{m}$ ,  
a resin, and an ultrafine inorganic powder having a particle size from [1 to 1000] 2 to 100 nm,  
and an exposed portion of the filler in the at least one through-hole structure is covered with a  
[portion of the at least one conductor circuit] through-hole-covering conductor layer.

Claim 18: The multilayer printed wiring board according to claim 17, wherein the filler is a nonconducting composition containing metal particles.

Claim 19: The multilayer printed wiring board according to claim 17, wherein the particulate substance comprises at least one of metal particles, inorganic particles and resin particles.

Claim 20: The multilayer printed wiring board according to claim 17, wherein the resin comprises at least one of bisphenol epoxy resin and novolac epoxy resin.

Claim 21 (amended): The multilayer printed wiring board according to claim 17, wherein [a roughened layer is formed on] a surface of the [at least one conductor circuit] through-hole-covering conductor layer covering the at least one through-hole structure is roughened.

Claim 22: The multilayer printed wiring board according to claim 17, wherein the substrate is a multilayer core substrate formed by laminating at least one conductor layer and at least one prepreg in alternating order.

Claim 23 (amended): The multilayer printed wiring board according to claim 17, wherein at least one through-hole structure formed [on] in the substrate has a pitch interval equal to or less than 700  $\mu\text{m}$ .

Claim 24 (amended): The multilayer printed wiring board according to claim 17, [comprising build-up wiring layers including the at least one via-hole provided in the at least one interlaminar resin insulating layer] wherein the at least one interlaminar resin insulating layer comprises a plurality of interlaminar resin insulating layers, the plurality of interlaminar resin insulating layers and at least one via-hole provided in the interlaminar resin insulating layers to form build-up wiring layers, and the build-up wiring layers are formed on both surfaces of the substrate[, ] and have the same number of layers [with each other] on both surfaces of the substrate.

Claim 25 (amended): A multilayer printed wiring board comprising:  
a substrate [provided with] having at least one through-hole structure, [the substrate having] the at least one through-hole structure comprising a plated film and being filled with a filler;

at least one interlaminar resin insulating layer formed [thereon] on the substrate; and  
at least one conductor circuit formed on the at least one interlaminar resin insulating layer[, the at least one through-hole structure being filled with filler],

wherein [an internal] a surface of the plated film of the at least one through-hole structure is roughened, [and] the filler comprises metal particles and one of thermosetting and thermoplastic [resin] resins, [and] an exposed surface of the filler in the at least one through-hole structure is covered with a [portion of the at least one conductor circuit] through-hole-covering conductor layer, and at least one viahole is formed in the at least one interlaminar resin insulating layer [just] directly above the [at least one conductor circuit and is connected to the at least one conductor circuit] through-hole-covering conductor layer.

Claim 26 (amended): The multilayer printed wiring board according to claim 25, wherein a [roughened layer is formed on] surface of the through-hole-covering conductor layer is roughened.

Claim 27: The multilayer printed wiring board according to claim 25, wherein the substrate is a multilayer core substrate formed by laminating at least one conductor layer and at least one prepreg in alternating order.

Claim 28 (amended): The multilayer printed wiring board according to claim 25, wherein the at least one through-hole structure formed [on] in the substrate has a pitch interval of equal to or less than 700  $\mu\text{m}$ .

Claim 29 (amended): The multilayer printed wiring board according to claim 25, [comprising build-up wiring layers including the at least one via-hole provided in the at least

one interlaminar resin insulating layer] wherein the at least one interlaminar resin insulating layer comprises a plurality of interlaminar resin insulating layers, the plurality of interlaminar resin insulating layers and at least one via-hole provided in the interlaminar resin insulating layers to form build-up wiring layers, and the build-up wiring layers are formed on both surfaces of the substrate[, and have the same number of layers [with each other] on both surfaces of the substrate.

Claim 30 (amended): A multilayer printed wiring board comprising:  
a substrate [provided with] having at least one through-hole structure, [the substrate having] the at least one through-hole structure being filled with a filler;  
at least one interlaminar resin insulating layer formed [thereon] on the substrate; and  
at least one conductor circuit formed on the at least one interlaminar resin insulating layer[, the at least one through-hole being filled with filler],  
wherein an internal surface of the at least one through-hole structure is roughened,  
and the filler comprises a particulate substance having a particle size of from 0.1 to 30  $\mu\text{m}$ , a resin, and an ultrafine inorganic powder having a particle size from [1 to 1000] 2 to 100 nm,  
and an exposed surface of the filler in the at least one through-hole structure is covered with a  
[portion of the at least one conductor circuit] through-hole-covering conductor layer, and at  
least one viahole is formed in the at least one interlaminar resin insulating layer [just] directly  
above the [at least one conductor circuit and is connected to the at least one conductor circuit]  
through-hole-covering conductor layer.

Claim 31: The multilayer printed wiring board according to claim 30, wherein the filler is a nonconducting composition containing metal particles.

Claim 32: The multilayer printed wiring board according to claim 30, wherein the particulate substance comprises at least one of metal particles, inorganic particles and resin particles.

Claim 33: The multilayer printed wiring board according to claim 30, wherein the resin comprises at least one of bisphenol epoxy resin and novolac epoxy resin.

Claim 34 (amended): The multilayer printed wiring board according to claim 30, wherein [a roughened layer is formed on] a surface of the [at least one conductor circuit covering the at least one through-hole] through-hole-covering conductor layer is roughened.

Claim 35: The multilayer printed wiring board according to claim 30, wherein the substrate is a multilayer core substrate formed by laminating at least one conductor layer and at least one prepreg in alternating order.

Claim 36 (amended): The multilayer printed wiring board according to claim 30, wherein the least one through-hole structure formed [on] in the substrate has a pitch interval of equal to or less than 700  $\mu\text{m}$ .

Claim 37 (amended): The multilayer printed wiring board according to claim 30, [comprising build-up wiring layers including the at least one via-hole provided in the at least one interlaminar resin insulating layer] wherein the at least one interlaminar resin insulating layer comprises a plurality of interlaminar resin insulating layers, the plurality of interlaminar resin insulating layers and at least one via-hole provided in the interlaminar resin insulating layers to form build-up wiring layers, and the build-up wiring layers are formed on both surfaces of the substrate[, ] and have the same number of layers [with each other] on both surfaces of the substrate.

Claim 38 (amended): A resin composition for filling through-hole of a printing wiring board comprising:

a particulate substance comprising metal [powder] particles having an average particle size ranging from 0.1 to 30  $\mu\text{m}$  and being present in an amount ranging from 30 to 90% by weight of the total solids content of the resin composition[,];

a resin and

an ultrafine inorganic powder having an average particle size ranging from [1 to 1,000] 2 to 100 nm.

Claim 39: The resin composition according to claim 38, which is a nonconducting composition.

Claim 40 (amended): The resin [compositon] composition according to claim 38, wherein the particulate substance further comprises at least one member selected from the group consisting of [metal particulate,] inorganic particles [or] and resin particles.

Claim 41: The resin composition according to claim 38, wherein the resin comprises at least one of bisphenol epoxy resin and novolac epoxy resin.

Claim 42: The resin composition according to claim 41, wherein the bisphenol epoxy resin comprises at least one of bisphenol P epoxy resin and bisphenol A epoxy resin.

Claim 43: The resin composition according to claim 41, wherein the novolac epoxy resin comprises at least one of phenol novolac epoxy resin and cresol novolac epoxy resin.

Claim 44: The resin composition according to claim 41, wherein the composition ratio of the novolac epoxy resin to the bisphenol epoxy resin ranges from 1/1 to 1/100 by weight.

Claim 45: The resin composition according to claim 38, wherein the ultrafine inorganic powder is present in an amount ranging from 0.1 to 5% by weight of the total solids content of the resin composition and has an average particle size ranging from 2 to 200 nm.

Claim 46 (amended): The resin composition according to claim 38, wherein the ultrafine inorganic powder [is] comprises at least one material selected from the group consisting of silica, alumina, silicon carbide [or] and mullite.

Claim 47: The resin composition according to claim 46, wherein the ultrafine inorganic powder is silica.

Claim 48 (amended): A process of producing a multilayer printed wiring board comprising:

forming a hole in a substrate;

[forming at least one conductor layer on both surfaces of a substrate by electroless plating,]

forming [at least one] a through-hole structure [on] in the substrate[[,]] by plating a layer on a surface of the hole;

[forming a roughened layer on] roughening [an internal] a surface of the plated layer of the [at least one] through-hole structure;[,]

filling the [at least one] through-hole structure including the plated layer having [the] a roughened [layer on its internal] surface with a filler comprising metal particles and one of thermosetting and thermoplastic resins [resin, and drying and curing the filler,];

forming a first conductor layer having a first conductor circuit on the substrate;

forming [at least one] a first interlaminar resin insulating layer on the first conductor circuit and the substrate;[, and]

forming an opening for a via hole in the interlaminar resin insulating layer; and

forming [at least one] a second conductor layer having a second conductor circuit [by electroless plating] on the first interlaminar resin insulating layer and the via hole in the opening,

wherein the via hole is formed to connect the first conductor circuit and the second conductor circuit.

Claim 49 (amended): The process according to claim 48, wherein the [internal] surface of the plated layer of the [at least one] through-hole structure is roughened by a treatment selected from the group consisting of an oxidation-reduction treatment, a treatment

with an aqueous mixed solution of an organic acid and a copper (II) complex, [or] and a plating treatment with a needle ternary alloy of copper-nickel-phosphorous.

Cancel Claim 50.

Claim 51 (amended): The process according to claim 48, wherein forming the [at least one conductor circuit] first conductor circuit and the second conductor circuit comprises electroplating after electroless plating.

Claim 52 (amended): A process of producing a multilayer printed wiring board, comprising:

forming a hole in a substrate;

[forming at least one conductor layer on both surfaces of a substrate by electroless plating,]

forming [at least one] a through-hole structure [through] in the substrate[,]  
by plating a layer on a surface of the hole;

[forming a roughened layer on] roughening [an internal] a surface of the plated layer  
of the [at least one] through-hole structure[:],]

filling the [at least one] through-hole structure including the plated layer having [the] a roughened [layer on its internal] surface with a filler comprising a particulate substance including metal particles having a particle size of from 0.1 to 30  $\mu\text{m}$ , a resin, and an ultrafine inorganic powder having a particle size from [1 to 1000] 2 to 100 nm[, and drying and curing the filler,];

forming a first conductor layer having a first conductor circuit on the substrate;

forming [at least one] a first interlaminar resin insulating layer on the first conductor circuit and the substrate[:], and]

forming an opening for a via hole in the first interlaminar resin insulating layer; and

forming [at least one] a second conductor layer having a second conductor circuit [by electroless plating] on the first interlaminar resin insulating layer and the via hole in the opening,

wherein the via hole is formed to connect the first conductor circuit and the second conductor circuit.

Claim 53 (amended): The process according to claim 52, wherein the filler is a nonconducting composition [containing metal particles].

Claim 54 (amended): The process according to claim 52, wherein the particulate substance further comprises at least one of [metal particles,] inorganic particles and resin particles.

Claim 55: The process according to claim 52, wherein the resin comprises at least one of bisphenol epoxy resin and novolac epoxy resin.

Claim 56 (amended): The process according to claim 52, wherein forming the [at least one] first conductor layer and the second conductor layer comprises electroplating after electroless plating.

Claim 57 (amended): The process according to claim 52, wherein forming the [at least one] first conductor circuit and the second conductor circuit comprises electroplating after electroless plating.

Cancel Claims 58-66.

Claim 67 (amended): The process according to claim [66] 52, wherein the filler is a nonconducting composition having a specific resistance of equal to or more than  $1 \times 10^6$  [ $\Omega \cdot \text{cm}^2$ ]  $\Omega \cdot \text{cm}$  [and containing metal particles].

Claim 68 (amended): The process according to claim 67, wherein the particulate substance further comprises at least one of [metal particles,] inorganic particles and resin particles.

Cancel Claims 69 and 70.

Claim 71 (amended): The process according to claim [66] 52, wherein the forming of the first conductor layer includes subjecting a portion of the filler in the through-hole to electroless plating [wherein forming the portion of the at least one conductor layer on the at least one through-hole comprises] and electroplating [after electroless plating] to cover the through-hole.

Claim 72 (amended): A process of producing a multilayer printed wiring board comprising:

forming a hole in a substrate;

[forming at least one conductor layer on both surfaces of a substrate by electroless plating,]

forming [at least one] a through-hole structure [on] in the substrate[,] by plating a layer on a surface of the hole;

[forming a roughened layer on] roughening [an internal] a surface of the plated layer of the [at least one] through-hole[,] structure;

filling the [at least one] through-hole structure including the plated layer having [the] a roughened [layer on its internal] surface with a filler comprising metal particles and one of [[the]] thermosetting and thermoplastic resins [resin, and drying and curing the filler,];

forming a [portion of the at least one] first conductor layer having a through-hole-covering conductor layer on the [at least one] through-hole structure [by subjecting a portion of the filler on the at least one through-hole to electroless plating,];

forming [at least one] a first interlaminar resin insulating layer[,] on the first conductor layer; and

forming at least one viahole in the first interlaminar resin insulating layer and [at least one] a second conductor circuit [in] on the [at least one] first interlaminar resin insulating layer, [located just above the at least one through-hole, and]

wherein the at least one viahole is formed at a position directly above the through-hole structure and provided to connect the through-hole-covering conductor layer with the second conductor circuit

[connecting the at least one viahole to the at least one conductor circuit in the at least one interlaminar resin insulating layer located just above the at least one through-hole].

Claim 73 (amended): The process according to claim 72, wherein the [internal] surface of the plated layer of the [at least one] through-hole structure is roughened by a treatment selected from the group consisting of oxidation-reduction treatment, treatment with an aqueous mixed solution of an organic acid and a copper (II) complex, [or] and plating treatment with needle ternary alloy of copper-nickel-phosphorus.

Claim 74 (amended): The process according to claim 72, wherein the forming the [portion of the at least one conductor layer] through-hole-covering conductor layer on the [at least one] through-hole structure comprises smoothing a surface of the substrate, applying catalyst nuclei to the smoothed surface of the substrate, subjecting the substrate to electroless plating to form a plating layer, subjecting the substrate to electroplating, forming an etching resist [just] directly above the [at least one] through-hole structure and on a portion of the [at least one] through-hole structure [and the plating layer which is to become a part of the at least one conductor circuit], removing the plating layer in a portion of the substrate where the etching resist is not formed, and removing the etching resist.

Claim 75 (amended): The process according to claim 72, wherein the forming the [portion of the at least one conductor layer] through-hole-covering conductor layer on the [at least one] through-hole structure comprises smoothing a surface of the substrate, subjecting

the substrate to electroless plating to form a plating layer, forming a plating resist on [a part of the smoothed surface of the substrate] the plating layer, subjecting [a portion of the smoothed surface of] the substrate to electroplating [where the resist is not formed to electroplating to form the at least one conductor layer and the at least one conductor circuit], [and] removing the plating resist, and [with] etching the [at least one conductor layer] plating layer located beneath the plating resist [by etching] to form the through-hole-covering conductor layer.

Claim 76 (amended): The process according to claim 72, wherein the forming the [portion of the at least one conductor layer] through-hole-covering conductor layer on the [at least one] through-hole structure comprises roughening a surface of the portion of the [at least one conductor layer] through-hole-covering conductor layer by a treatment selected from the group consisting of oxidation-reduction treatment, treatment with an aqueous mixed solution of an organic acid and a copper (II) complex, [or] and plating treatment with needle ternary alloy of copper-nickel-phosphorus.

Cancel Claims 77 and 78.

Claim 79 (amended): The process according to claim 72, wherein forming [at least one] the first conductor layer on both surfaces of [a] the substrate comprises electroplating after electroless plating.

Claim 80 (amended): The process according to claim 72, wherein forming [a portion of the at least one conductor layer] through-hole-covering conductor layer on the [at least one] through-hole structure comprises electroplating after electroless plating.

Claim 81 (amended): A process of producing a multilayer printed wiring board comprising:

forming a hole in a substrate;

[forming at least one conductor layer on both surfaces of a substrate by electroless plating,]

forming [at least one] a through-hole structure [on] in the substrate[,], by plating a layer on a surface of the hole;

[forming a roughened layer on] roughening [an internal] a surface of a plated layer of the [at least one] through-hole structure,

filling the [at least one] through-hole structure including the plated layer having [the] a roughened [layer on its internal] surface with a filler comprising a particulate substance having a particle size of from 0.1 to 30  $\mu\text{m}$ , a resin, and an ultrafine inorganic powder having a particle size from [1 to 1000] 2 to 100 nm[, and drying and curing the filler,];

forming a [portion of the at least one] first conductor layer having a through-hole-covering conductor layer on the [at least one] through-hole structure; [by subjecting a portion of the filler on the at least one through-hole structure to electroless plating,]

forming [at least one] a first interlaminar resin insulating layer[,]; and

forming at least one viahole in the first interlaminar resin insulating layer and [at least one] a second conductor circuit [in] on the [at least one] first interlaminar resin insulating layer, [located just above the at least one through-hole, and]

wherein the viahole is formed at a position directly above the through-hole structure and provided to connect the through-hole-covering conductor layer with the second conductor circuit

[connecting the at least one viahole to the at least one conductor circuit in the at least one interlaminar resin insulating layer located just above the at least one through-hole].

Claim 82 (amended): The process according to claim 81, wherein the filler is a nonconducting composition and [further] the particulate substance comprises metal particles.

Claim 83 (amended): The process according to claim [82] 81, wherein the particulate substance comprises at least one of metal particles, inorganic particles and resin particles.

Claim 84: The process according to claim 82, wherein the resin comprises at least one of bisphenol epoxy resin and novolac epoxy resin.

Claim 85 (amended): The process according to claim 82, wherein forming the [at least one] first conductor layer comprises electroplating after electroless plating.

Claim 86 (amended): The process according to claim 82, wherein forming the [portion of the at least one] first conductor layer on the [at least one] through-hole structure comprises electroplating after electroless plating.

Claim 87 (amended): A multilayer printed wiring board comprising:  
a substrate having a through-hole structure comprising a plating layer and a filler provided in the through-hole structure, the plating layer having a roughened portion;  
a first conductor layer having a first conductor circuit formed on the substrate and a through-hole-covering conductor layer covering the filler provided in the through-hole structure having the plating layer;  
a first interlaminar resin insulating layer having a via hole and being formed on the substrate and the first conductor layer; and  
a second conductor layer having a second conductor circuit formed on the first interlaminar resin insulating layer, the second conductor circuit being connected to the first conductor circuit by the via hole.

Claim 88 (amended): The multilayer printed wiring board according to Claim 87, wherein said via hole is [filled] plated with a plated film or filled with a filler.

Claim 89 (amended): The multilayer printed wiring board according to Claim 87,  
wherein a surface of said through-hole-covering conductor layer is roughened.

Claim 90 (amended): The multilayer printed wiring board according to Claim 89, wherein a side face of said through-hole-covering conductor layer is roughened.

Claim 91 (amended): The multilayer printed wiring board according to Claim 87, wherein [further comprising:

a roughened layer provided in said at least one through-hole and having the] the roughened portion of the plating layer forms a roughened internal surface, and the plating layer has a thickness of [the roughened layer being] at least 0.1  $\mu\text{m}$  and at most 10  $\mu\text{m}$ .

Claim 92 (previously presented): The multilayer printed wiring board according to Claim 87, wherein said substrate comprises a glass-epoxy substrate, a polyimide substrate, a bismaleimide-triazine resin substrate, a fluoro-resin substrate, a copper-clad laminate resin substrate, a ceramic substrate, or a metal substrate.

Claim 93 (new): The multilayer printed wiring board according to Claim 1, wherein the filler is non-conductive.

Claim 94 (new): The multilayer printed wiring board according to Claim 12, wherein the filler is non-conductive.

Claim 95 (new): The multilayer printed wiring board according to Claim 25, wherein the filler is non-conductive.

Claim 96 (new): The process according to Claim 48, wherein the forming of the first conductor layer comprises forming a through-hole-covering conductor layer which covers the filler.

Claim 97 (new): The process according to Claim 96, wherein the via hole is formed on the through-hole-covering conductor layer and located directly over the filler.

Claim 98 (new): The process according to Claim 48, wherein the filler is a nonconductive composition.

Claim 99 (new): The process according to Claim 48, wherein the substrate comprises copper-clad laminate, and the filler protruded from the through-hole structure is removed by polishing.

Claim 100 (new): The process according to Claim 48, wherein the forming of the first conductor layer comprises forming a through-hole-covering conductor layer to cover the filler, and the forming of the through-hole-covering conductor layer comprises performing electroless plating and electroplating after the electroless plating.

Claim 101 (new): The process according to Claim 52, wherein the forming of the first conductor layer includes forming a through-hole-covering conductor layer which covers the filler.

Claim 102 (new): The process according to Claim 101, wherein the via hole is formed on the through-hole-covering conductor layer and located directly over the filler.

Claim 103 (new): The process according to Claim 52, wherein the substrate is copper-clad laminate and the filler protruded from the through-hole structure is removed by polishing.

Claim 104 (new): The process according to Claim 52, wherein the forming of the first conductor layer includes forming a through-hole-conductor layer which covers the filler, and the forming of the through-hole-conductor layer includes performing electroless plating and electroplating after the electroless plating.

Claim 105 (new): The multilayer printed wiring board according to Claim 87, wherein the via hole is formed on the through-hole-covering conductor layer.

Claim 106 (new): The multilayer printed wiring board according to Claim 87, wherein the via hole is formed on the through-hole-covering conductor layer, and the via hole is formed above the filler.

Claim 107 (new): The multilayer printed wiring board according to Claim 87, wherein the through-hole-covering conductor layer comprises an electroless plating film and an electroplating film on the electroless plating film.

Claim 108 (new): The multilayer printed wiring board according to Claim 87, wherein the filler comprises metal particles.

Claim 109 (new): The multilayer printed wiring board according to Claim 108, wherein the filler is non-conductive.

Claim 110 (new): A process of producing a multilayer printed wiring board comprising:

forming a hole in a substrate;  
forming a through-hole structure in the substrate by plating a layer on a surface of the hole;  
roughening a portion of the plating layer of the through-hole structure;  
filling a filler inside the through-hole structure;  
forming a first conductor layer having a first conductor circuit on the substrate and a through-hole-covering conductor layer covering the filler;  
forming a first interlaminar resin insulating layer on the first conductor layer and substrate;  
forming an opening for a via hole in the interlaminar resin insulating layer; and  
forming a second conductor layer having a second conductor circuit on the first interlaminar resin insulating layer and the via hole in the opening,  
wherein the via hole is formed to connect the first conductor circuit and the second conductor circuit.

Claim 111 (new): The process according to Claim 110, wherein the via hole is formed on the through-hole-covering conductor layer at a position directly above the filler.

Claim 112 (new): The process according to Claim 110, wherein the filler comprises metal particles and one of thermosetting and thermoplastic resins.